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**U.S. UTILITY Patent Application**

JCGO

10 O.I.P.E.  
SCANNED KC3 Q.A. 10

PATENT DATE

APPLICATION NO.	CONT/PRIOR	CLASS <del>156</del> 438	SUBCLASS 710	ART UNIT <del>1763</del> 1763	EXAMINER Goudrean
09/884805	D				

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## Confinement device for use in dry etching of substrate surface and method of dry etching a wafer surface

PTO-2040  
12/03

## **ISSUING CLASSIFICATION**

TERMINAL DISCLAIMER	DRAWINGS			CLAIMS ALLOWED	
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.
<input type="checkbox"/> The term of this patent subsequent to _____ (date) has been disclaimed.				<b>NOTICE OF ALLOWANCE MAILED</b>	
	(Assistant Examiner)	(Date)			
<input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S Patent. No. _____				<b>ISSUE FEE</b>	
	(Primary Examiner)	(Date)		Amount Due	Date Paid
<input type="checkbox"/> The terminal _____ months of				<b>ISSUE BATCH NUMBER</b>	

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Fomr PTO-438A  
(Rev. 8/89)

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